

Alert: March 5, 2020

On January 29, 2020 the United States Environmental Protection Agency (EPA) activated the “*Emerging Viral Pathogen Guidance for Antimicrobial Pesticides*” in response to the discovery of the novel coronavirus, SARS-COV-2. The guidance, issued in 2016, details a process by which companies holding current EPA registrations under the Federal Insecticide Fungicide and Rodenticide Act (FIFRA) for certain disinfectant products can promote those products for use against “emerging pathogens” like the coronavirus.

On January 12, 2015, prior to this ruling, “***Path-Away Anti-Pathogenic Aerosol Solution***” was already declared “***exempt from registration***” by qualifying as a minimum risk pesticide as defined under the Federal Insecticide, Fungicide, and Rodenticide Act (FIFRA) section 25(b), outlined in title 40 of the Code of Federal Regulations (CFR), section 152.25, and in title 3, California Code of Regulations section 6147. ***Path-Away Anti-Pathogenic Aerosol Solution*** is an organic based solution certified with “*Organic Input*” with “*no GMO*” components and meets registration regulations on a global basis.

Path-Away Anti-Pathogenic Aerosol Solution, registered with the United States of America Patent and Trademark Office, #4,032,774, was scientifically developed by Arthur V. Martin, Ph.D., president of Global Infection Control Consultants, LLC. It is a broad spectrum anti-pathogenic product with proven efficacy against 170+ individual pathogens including a wide range of fungi, bacteria, yeasts ***and viruses*** including H1N1, Mycobacterium *tuberculosis*, Influenza and others. ***Path-Away Anti-Pathogenic Aerosol Solution*** received this rare exemption due to its high efficacy combined with extremely low toxicity.

Path-Away Anti-Pathogenic Aerosol Solution is available through a very select group of globally based representatives. Contact our office (amartin@giccllc.com) for the representative near you.

Arthur V. Martin, Ph.D.

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